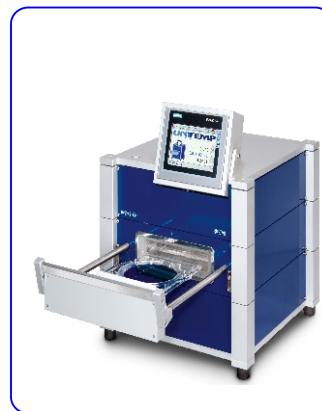


RAPID THERMAL ANNEALING OVENS (03.2018)



Model	RTP-100	RTP-100-HV	RTP-150	RTP-150-HV	RTP-150-EP
max. substrate size	100 x100mm	100 x100mm	156 x 156mm	156 x 156mm	156 x 156mm
T _{max}	1200 °C	1200 °C	1000 °C	1000 °C	1000 °C
T °C max.	1200 °C	1200 °C	1000 °C	1000 °C	1000 °C
Ramp up rate	150 K/sec	150 K/sec	75 K/sec	75 K/sec	150 K/sec
Vacuum up to	10 ⁻³ hPa	10 ⁻⁶ hPa	10 ⁻³ hPa	10 ⁻⁶ hPa	10 ⁻³ hPa
Flowmeter	MFC	MFC	MFC	MFC	MFC
Controller	SIMATIC®	SIMATIC®	SIMATIC®	SIMATIC®	SIMATIC®
Touch Panel	7"	7"	7"	7"	7"
Dimension	504x504(700)x570mm	504x504(700)x690mm	504x504(700)x570mm	504x504(700)x690mm	504x504(700)x570mm